

Scientists explain the pseudocapacitance phenomenon in supercapacitors

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Credit: Skoltech

Scientists in Russia and Armenia have predicted a new surface reconstruction of RuO_2 that explains the origin of charge storage in supercapacitors. The miniaturization of electronic devices to the nanometer scale will increase the role of surface and quantum effects in terms of the properties and stability of the whole device. Surface science has therefore become crucial for future technological advances.



At present, RuO_2 is the most commonly used material for electronic applications such as sensing and catalysis. It is widely used in supercapacitors as a cathode material. However, RuO_2 has puzzled researchers with respect to its application in supercapacitors.

Usually, supercapacitive behavior occurs as a result of the protonelectron double insertion process. Each adsorbed or intercalated hydrogen atom (proton) will induce pseudocapacitance in the <u>cathode</u> <u>material</u>. Experimental results show pseudocapacitance in the RuO₂ cathodes, but cannot explain the effect's origin, because this atomicscale process cannot be examined using available experimental techniques. A great deal of theoretical research has been devoted to the surface of RuO₂ with (110) crystallographic orientation, which is most stable at ambient conditions. Still, the pseudocapacitance effect remains unexplained.

"We predicted the new thermodynamically stable reconstruction of the RuO_2 surface with (110) crystallographic orientation, namely RuO_4 –(2×1). This reconstruction has one four-coordinate Ru atom and four oxygen atoms, two of which are two-coordinate and the other two of which are one-coordinate. A detailed investigation of the stability shows that a newly predicted reconstruction has lower surface energy compared to previously studied surfaces and terminations of surface with (110) crystallographic orientation, and should form even at ambient conditions, which does not contradict experimental data," said Alexander Kvashnin, a researcher with the Skoltech Center for Electrochemical Energy Storage and one of the study's authors.

To discriminate between structural models, scientists used the results of experiments carried out using scanning transmission microscopy (STM). They simulated the STM images of RuO_4 –(2×1) reconstruction along with a number of previously proposed surfaces and reconstructions and compared the simulations with experimentally available STM images. To



their surprise, they did not find any differences between the images, which made them difficult to distinguish in experiments. While equally consistent with experimental STM images, predicted reconstruction is lower in energy and is therefore preferable.

A further investigation of electrochemical properties shows that hydrogen adsorption with respect to the predicted reconstruction is energetically favorable, exhibiting a predominant influence of hydrogen intercalation into the cathode surface, which would contribute to pseudocapacitance. These results are in stark contrast to the obtained results from other surface reconstructions and terminations in which hydrogen intercalation is unfavorable.

"Combining the data on the lowest surface energy of the newly predicted RuO_4 -(2×1) surface reconstruction of (110) surface of RuO2, the perfect match of simulated STM image with experimental data and studied electrochemical properties, we explain the contribution of the surface redox reaction to the pseudocapacitance of RuO_2 cathodes, which is due to the special atomic structure of the surface reconstruction of (110) <u>surface</u>," said Kvashnin The results of their study was recently published in *Scientific Reports*.

More information: Zakaryan HA, Kvashnin AG, Oganov AR. Stable reconstruction of the (110) surface and its role in pseudocapacitance of rutile-like RuO2. *Scientific Reports*. 2017;7:10357. DOI: 10.1038/s41598-017-10331-z

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